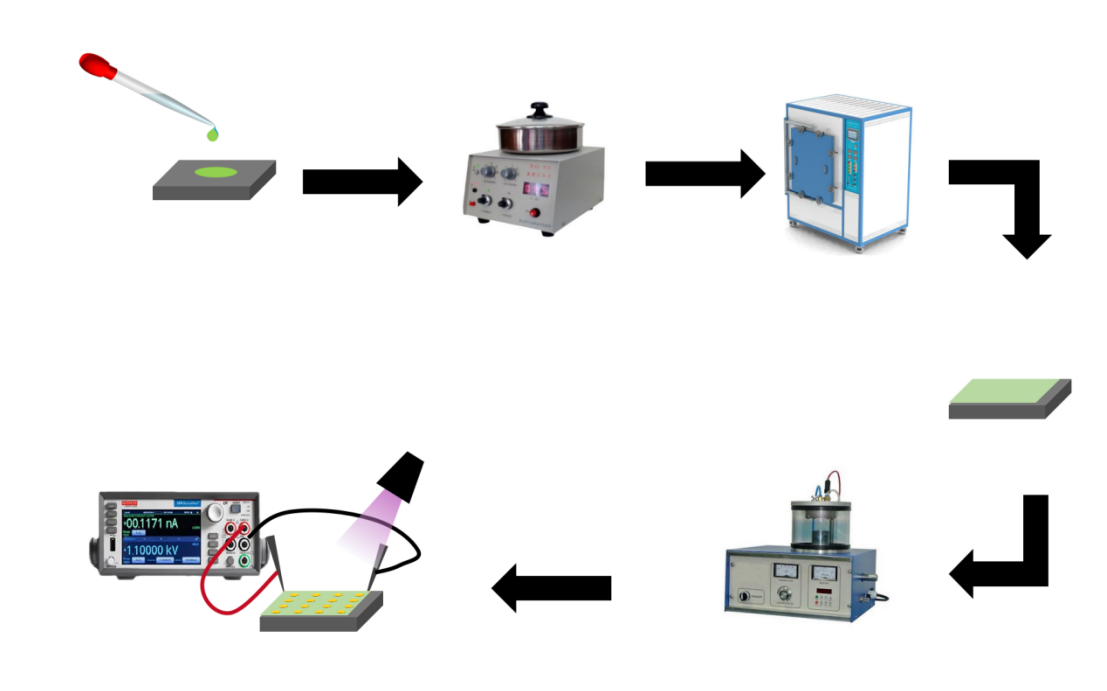


## Supporting Information

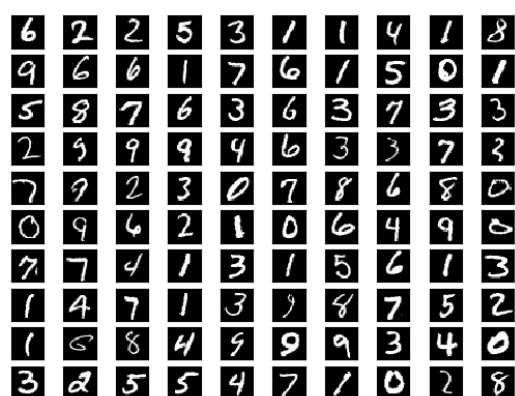
### Note 1. Preparation process of thin film devices



**Figure S1.** The overall preparation process of thin film devices

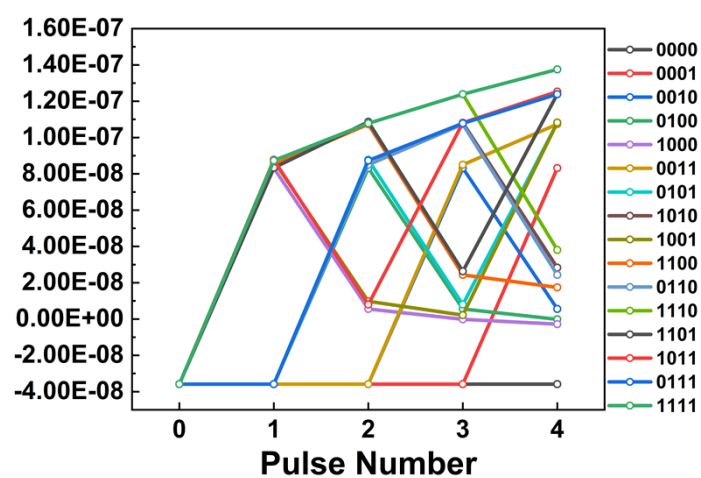
### Note 2. Neuromorphic calculation of device

**Figures S2** show handwritten digit sets for neural network recognition tests.



**Figure S2.** Handwritten digit set for testing.

Note 3.16 states of the device excited by 365 nm light



**Figure S3.** The device excites 16 different conduction states under the combined pulse of 365 nm light.